

TEAM-100

Automatic Wafer Protective Tape Lamination System

Outline

The ideal system for laminating tape within the circumference of the wafer prior to the backgrind process.

Features

Vacuum chamber application eliminates air bubbles and preserves integrity of wafers. Normal B/G tape roll applicable. Pre-cut tape is not necessary.

Ability to determine the diameter of the cut and laminate within the circumference of the wafer.



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Specification		TEAM-100
Throughput		50 wafers/hour (Depend on data setting)
Wafer Size		5 inch, 6 inch, 8 inch
Tape Width		8 inch : W 150mm, 6 inch : W 180mm, 8 inch : W 230mm
Utilities	Power	AC100V Single phase 50 / 60Hz 2.0 KVA
	Air	Pressure 0.5Mpa 100Nl/min
	Vacuum sourse	74Кра
Dimensions		D 1,000 × W 1,400 × H 1,650 mm
Weight		600 kg

System appearance and specifications are subject to change without prior notice from the supplier.

313-1 Shindo-cho, Kashihara City, Nara, Japan 634-8580

Phone: +81 (0) 744-24-7670 Fax: +81 (0) 744-24-8352